

Unravelling synthetic key parameters for the design of spin-crossover nanoparticles based on iron(II)-triazole coordination polymers: towards a control of the spin transition

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Supporting Information

General reverse-micelle protocol for the preparation of [Fe(Htrz)₂(trz)](BF₄)·H₂O (1) NPs.

- S1. Size analysis and elemental analysis.
- S2. Stabilization time for the Fe^{II} microemulsions as a function of the metal concentration (0.1–1.5 M).
- S3. Images of microemulsion stabilization.

Controlling size in [Fe(Htrz)₂(trz)](BF₄)·H₂O NPs: size effect of ω_0 variation.

- S4. Size analysis and elemental analysis.
- S5. XRPD analysis.
- S6. HR-TEM analysis.
- S7. AFM analysis.

References

General reverse-micelle protocol for the preparation of $[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4)\cdot\text{H}_2\text{O}$ (1) NPs.

Table S1. Size (DLS-based) and elemental analysis for NPs synthesized with different $[\text{Fe}]$.

$[\text{Fe}]$	Size (nm)	Elemental analysis	C [%]	N [%]	H [%]	S [%]	MW
0.5	25	experimental	33.57	22.39	4.49	3.21	
		$[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4)\cdot\text{H}_2\text{O}\cdot(\text{AOT})_{0.6}$	34.18	19.93	4.97	3.04	635,79
1	15	experimental	19.87	32.31	3.13	0.22	
		$[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4)\cdot\text{H}_2\text{O}\cdot(\text{AOT})_{0.02}$	20.51	33.64	2.62	0.17	374,73
1.5	11	experimental	19.08	30.85	2.39	0.41	
		$[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4)\cdot\text{H}_2\text{O}\cdot(\text{AOT})_{0.04}$	21.29	32.86	2.75	0.33	383,62

Figure S2. Representation of the stabilization time for the Fe^{II} microemulsions as a function of the metal concentration (0.1–1.5 M) with $\omega_0 = 5$ (the black line serves as a reference to linearity).

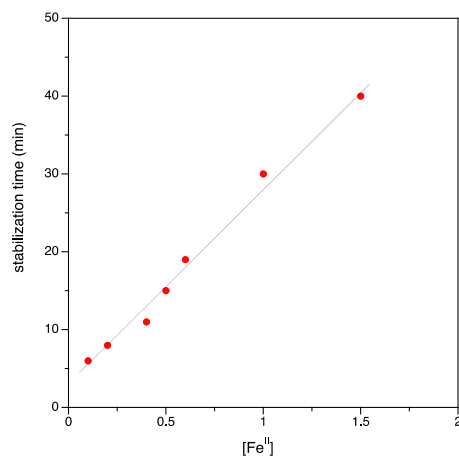
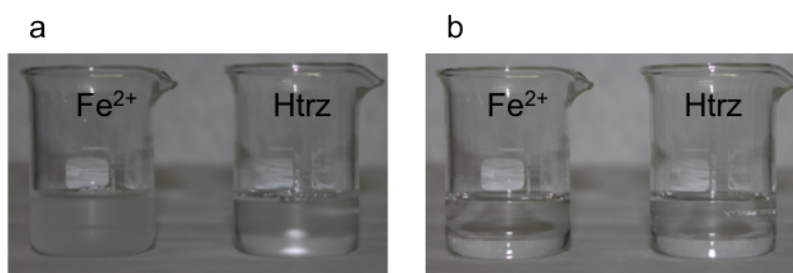


Figure S3. Pictures of the two micellar solutions before (a) and after (b) micelle stabilization upon stirring showing the difference in transparency.



Controlling size in $[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4)$ NPs: size effect of ω_0 variation.

Table S4. Table of size and elemental analysis for samples **1.16**, **1.10** and **1.2**.

Sample	Size (nm)	Elemental analysis	C [%]	N [%]	H [%]	S [%]	MW
1.16	16	experimental	25.59	28.93	3.48	1.77	
1.10	10	experimental	26.24	28.82	3.38	1.66	

1.2	4	experimental	29.63	26.13	3.99	2.54	
Theoretical		$[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4) \cdot \text{H}_2\text{O} \cdot (\text{AOT})_{0,2}$	26,74	28,06	6,68	0,71	449,25
Theoretical		$[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4) \cdot \text{H}_2\text{O} \cdot (\text{AOT})_{0,3}$	28,87	25,25	4,06	1,93	499,21

Figure S5. X-ray powder diffraction (XRPD) patterns of samples **1.6** (16 nm), **1.10** (10 nm) and **1.2** (4 nm) obtained on powdered samples. The patterns of the NPs bearing different sizes are compared with the experimental pattern of microcrystalline powder of $[\text{Fe}(\text{Htrz})_2(\text{trz})](\text{BF}_4) \cdot \text{H}_2\text{O}$ (**1**) obtained as bulk.¹

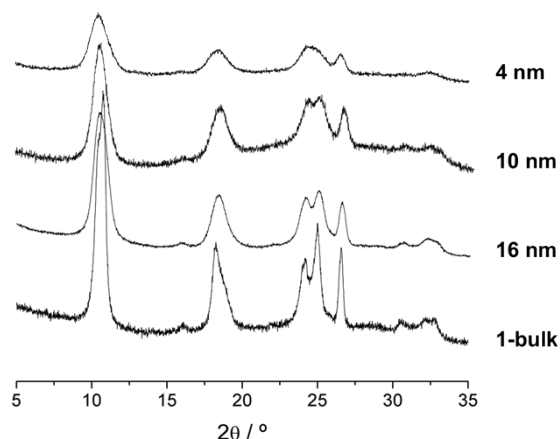


Figure S6. HR-TEM image of sample **1a** (ca. 16 nm) showing the two different orientations (parallel or standing) after sample deposition by drop casting. These two different orientations have been also observed by some of us in self-assembled monolayers of these NPs, using high-angle annular dark field scanning transmission electron microscopy (STEM-HAADF).²

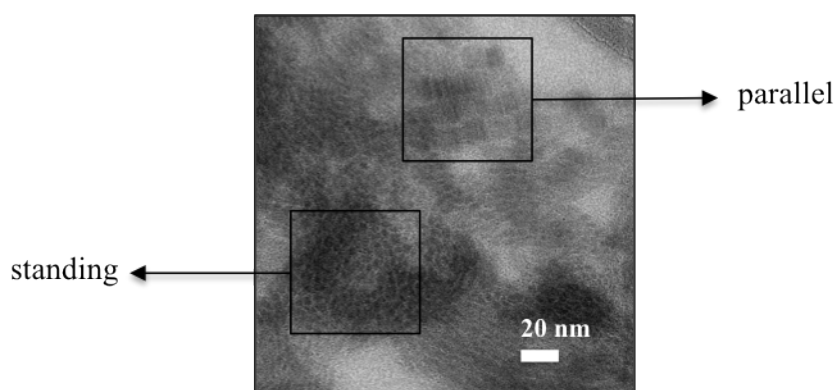
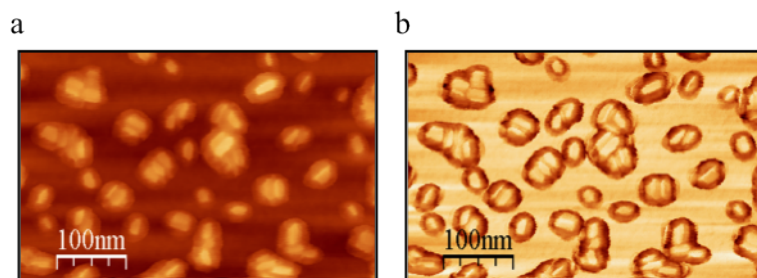


Figure S7. AFM (topography (a) and phase (b)) images measured in tapping mode for SCO-NPs (sample **1.16**, 16 nm) deposited by drop casting on native SiO_2 .

Silicon substrate cleaning process. Substrates of ca. 1 cm² were sonicated for 10 minutes in a freshly-prepared $\text{H}_2\text{O}_2:\text{NH}_4\text{OH}:\text{H}_2\text{O}$ (1:1:2) solution (x3 times). The substrates are then rinsed with mili-Q water, sonicated 5 minutes in mili-Q water (x2 times) and finally dried under a N_2 stream (*ultrasonic cleaner*: BRANASONIC MTH-5510 ultrasonic cleaner, power 185 W).

Drop casting deposition: A drop of the SCO-NP suspension is dropped on top of the substrate and left unperturbed for 30 second. Then, the substrate is rinsed with *n*-octane and dried under a N₂ stream.



References

- ¹ A. Grosjean, P. Négrier, P. Bordet, C. Etrillard, D. Mondieig, S. Pechev, E. Lebraud, J.-F. Létard, P. Guionneau, *Chem. Commun.* **2011**, 47, 12382.
- ² J. Dugay, M. Giménez-Marqués, T. Kozlova, H. W. Zandbergen, E. Coronado, H. S. J. van der Zant, *Adv. Mater.* **2015**, 27, 1288.